

Supplementary information to “From vineyards to reshaping materials: α -CF₂ activation in 100 % resveratrol-based catalyst-free vitrimers”

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Resveratrol α,α -difluorotriester “RvOEt” characterizations

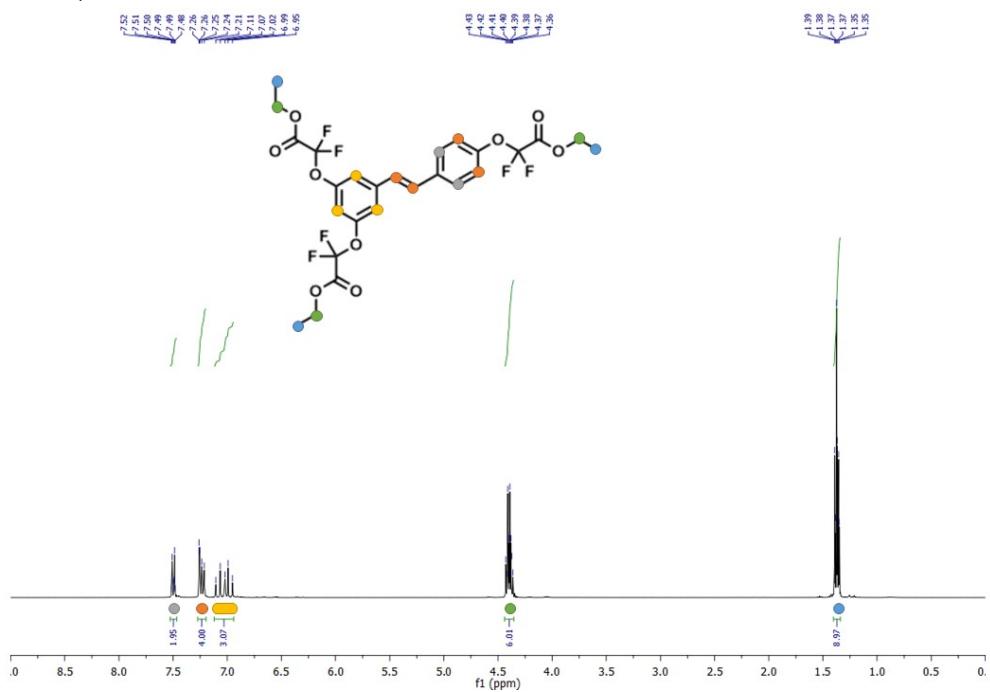


Figure S1. ^1H NMR spectrum of RvOEt in CDCl_3

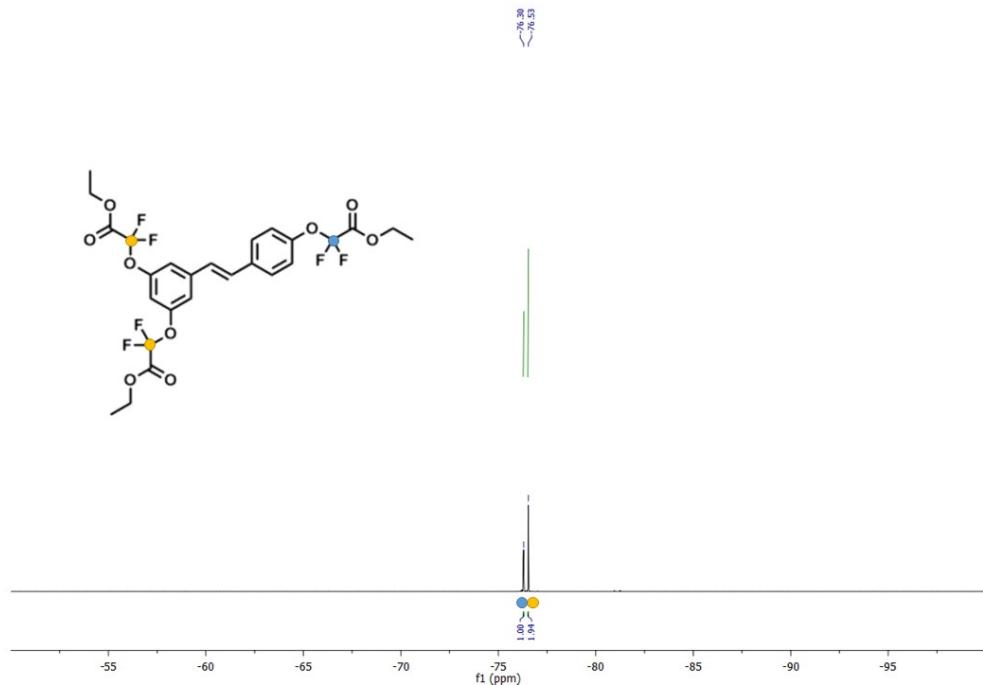


Figure S2. ^{19}F NMR spectrum of RvOEt in CDCl_3

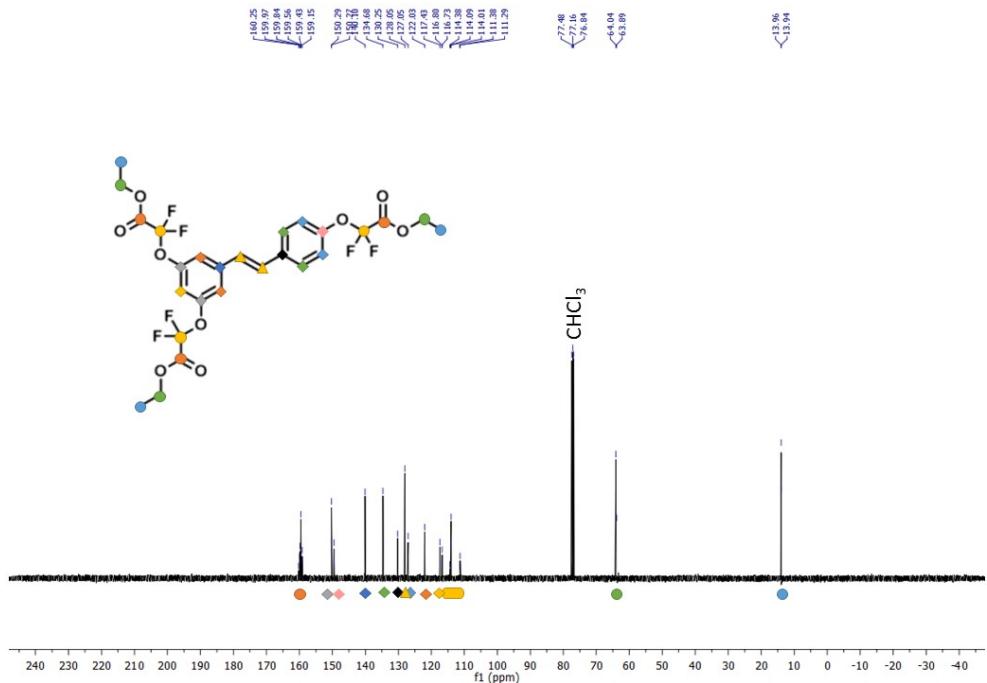


Figure S3. ^{13}C NMR spectrum of RvOEt in CDCl_3

Resveratrol α,α -difluorotriacid “RvOH-TAF” characterizations

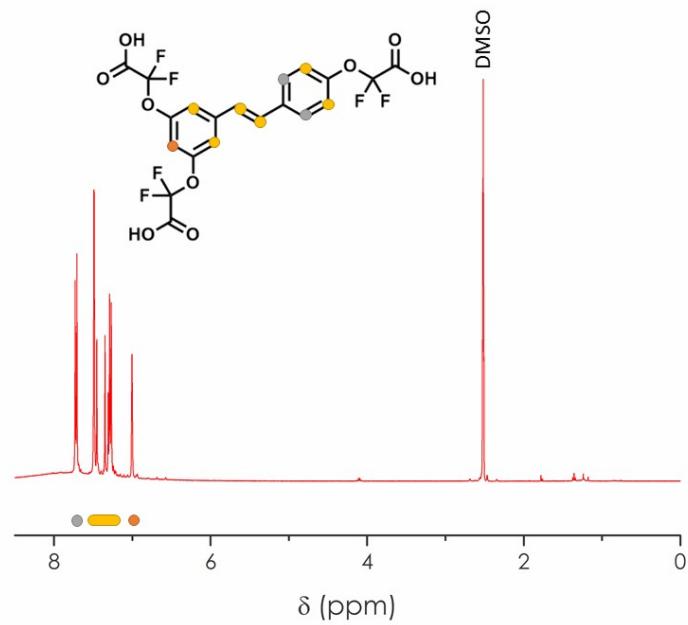


Figure S4. ^1H NMR spectrum of *RvOH-TAF* in $\text{DMSO}-d_6$

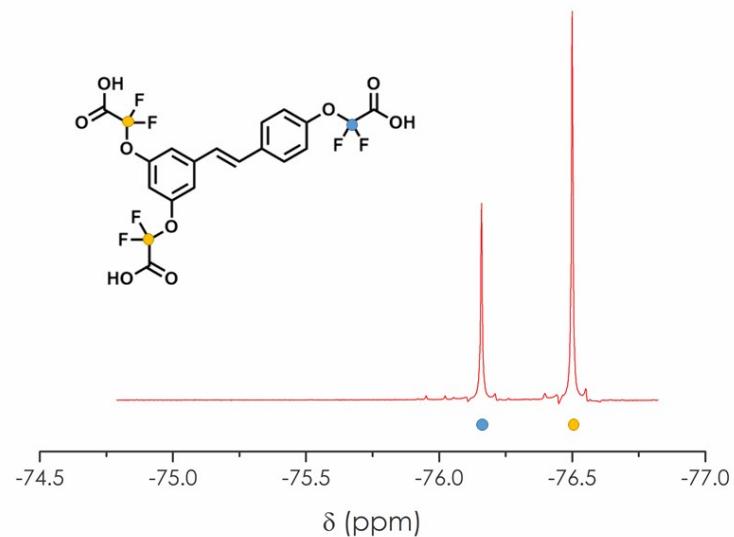


Figure S5. ^{19}F NMR spectrum of RvOH-TAF in $\text{DMSO}-d_6$

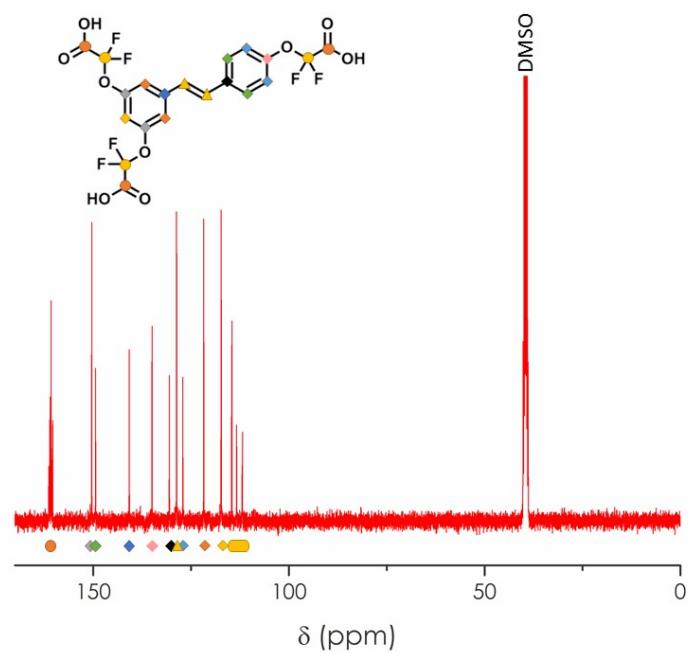


Figure S6. ^{13}C NMR spectrum of RvOH-TAF in $\text{DMSO}-d_6$

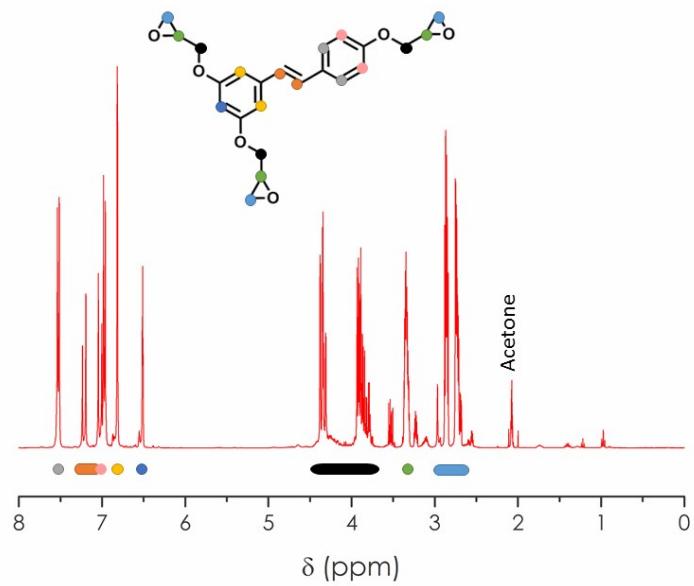


Figure S7. ^1H NMR spectrum of RvOGly in acetone- d_6

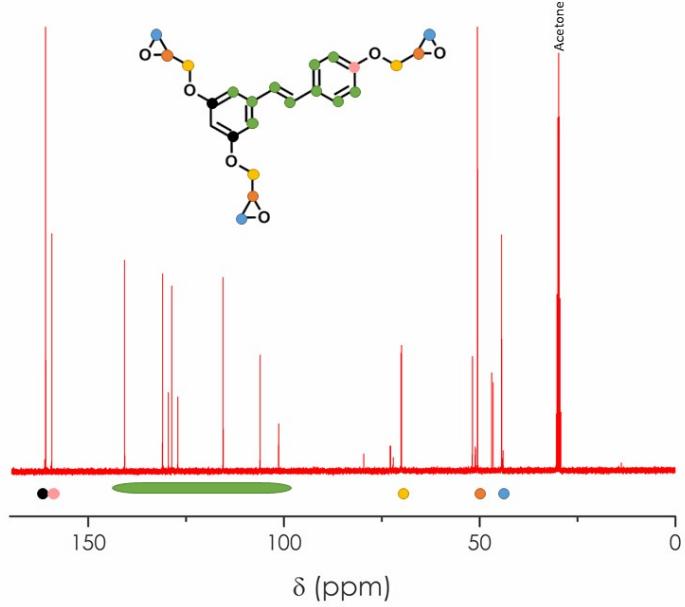
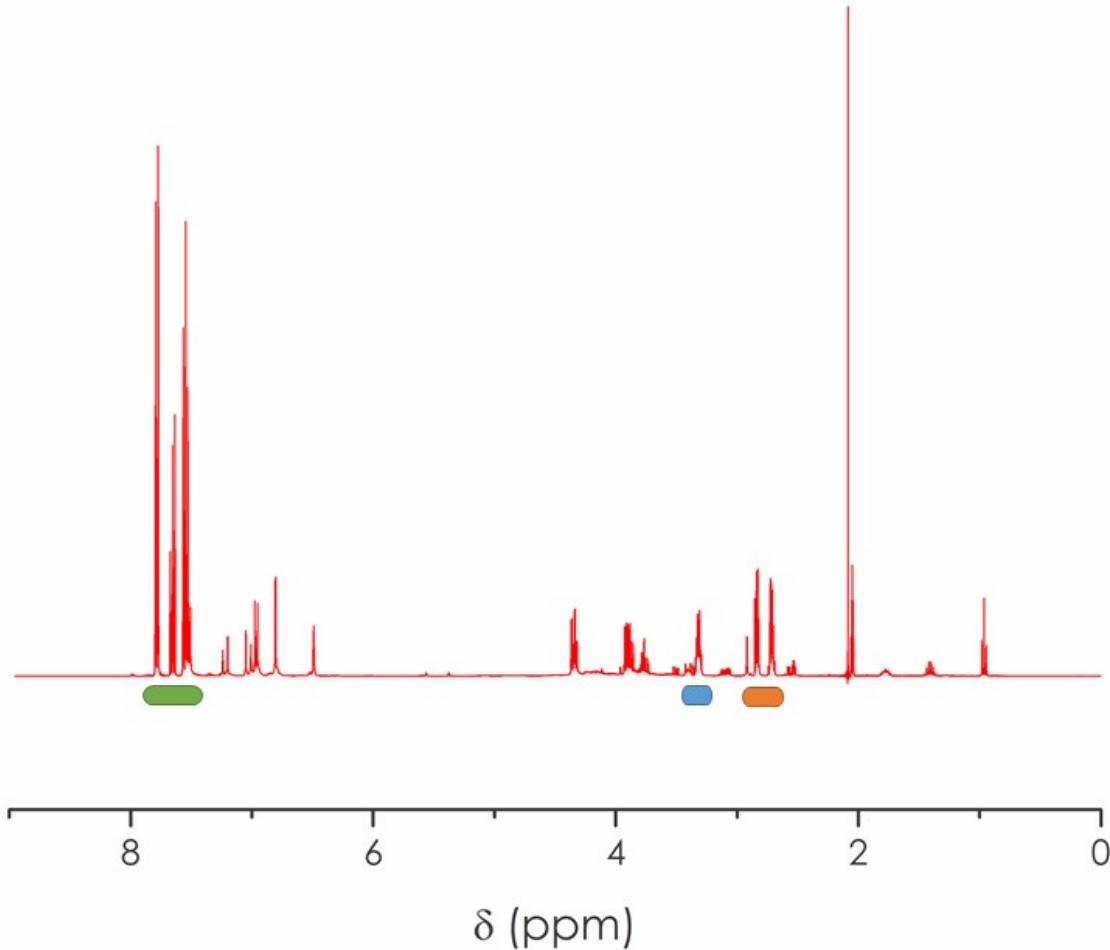


Figure S8. ^{13}C NMR spectrum of RvOGly in acetone- d_6

A. Experimental procedure for the determination of RvOGly epoxy equivalent weight (EEW) by ^1H NMR



50 to 70 mg of BDGE and 50 to 130 mg of RvOGly were dissolved in deuterated acetone. ^1H NMR spectra were integrated in the 7.87-7.28 ppm range for benzophenone protons (10 H), in the 3.46-3.26 ppm range for CH oxirane and in the 3.0-2.65 range for CH_2 oxirane. EEW was calculated as follows :

$$EEW_{CH} = \frac{m_{BDGE} \times \int_{7.28}^{7.87} \text{benzophenone} \times M_{benzophenone}}{10 \times m_{benzophenone} \times \int_{3.26}^{3.46} \text{CH oxirane}}$$

$$EEW_{CH_2} = \frac{2 \times m_{BDGE} \times \int_{7.28}^{7.87} \text{benzophenone} \times M_{benzophenone}}{10 \times m_{benzophenone} \times \int_{2.65}^{3.0} \text{CH}_2 \text{ oxirane}}$$

m_{epoxy} (mg)	$m_{benzophenone}$ (mg)	$\frac{\int_{7.28}^{7.87} CH \text{ oxirane}}{\int_{7.28}^{7.87} benzophenone}$	$\frac{\int_{7.28}^{7.87} CH_2 \text{ oxirane}}{\int_{7.28}^{7.87} benzophenone}$	EEW_{CH}	EEW_{CH_2}
55.9	39.9	0.157	0.283	163	180
94.8	44.8	0.227	0.390	170	198
125.9	54.8	0.245	0.402	171	208
Average EEW				$182 \pm 8 \text{ g/eq}$	

Vitrimer characterizations (Vm-RvOH)

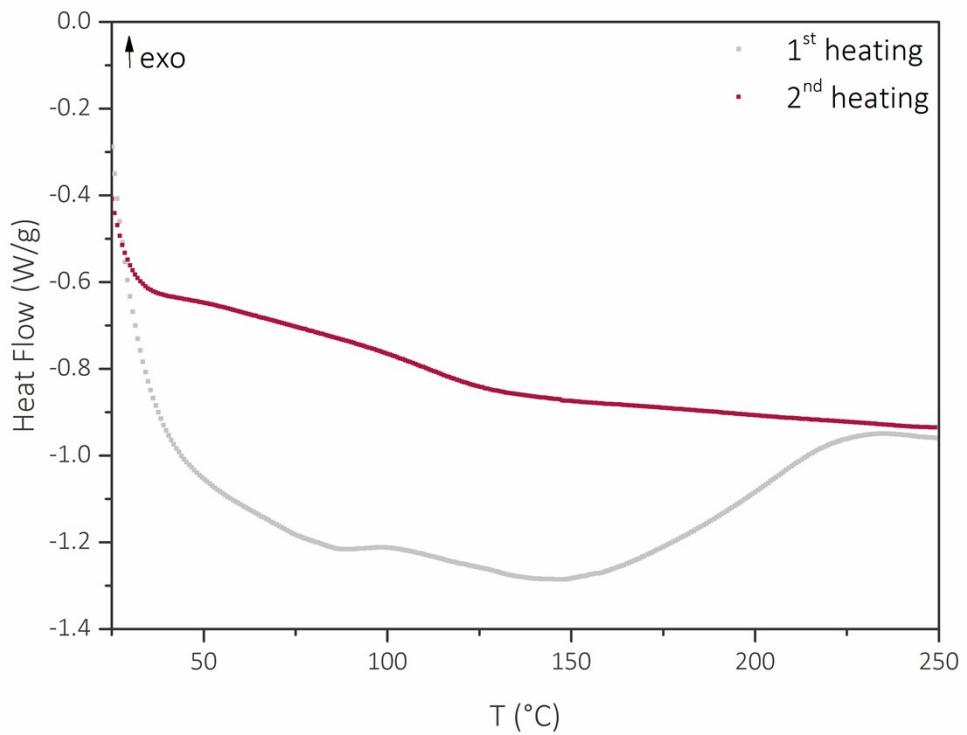


Figure S9. DSC thermogram of Vm-RvOH after curing 3 h at room temperature

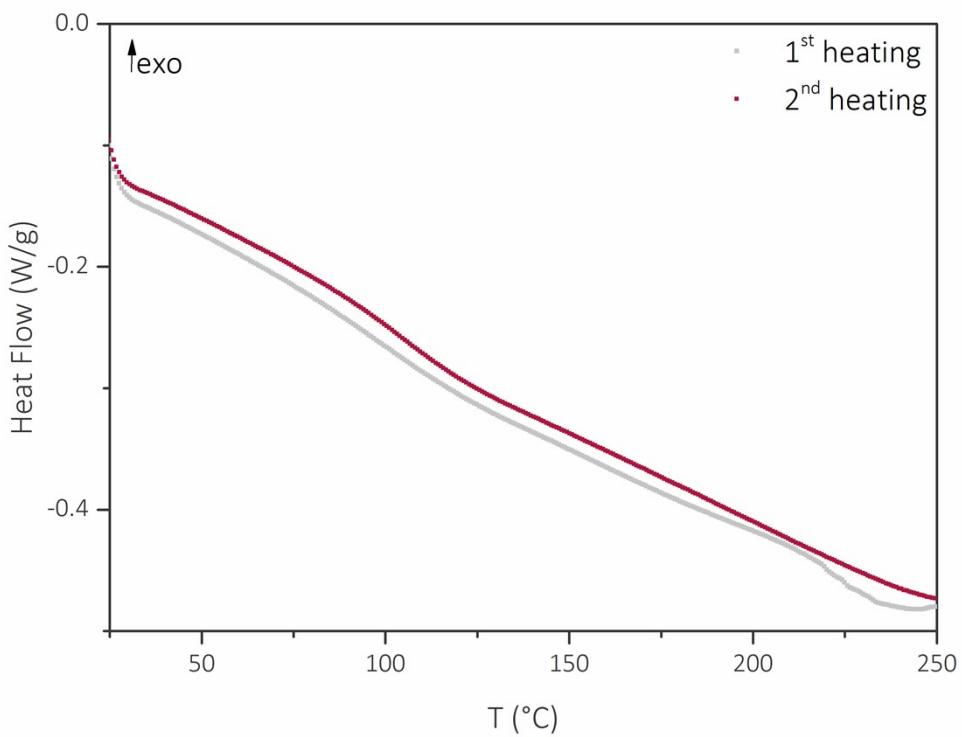


Figure S10. DSC thermogram of Vm-RvOH after curing 3 h at room temperature and 1 h at 150 °C

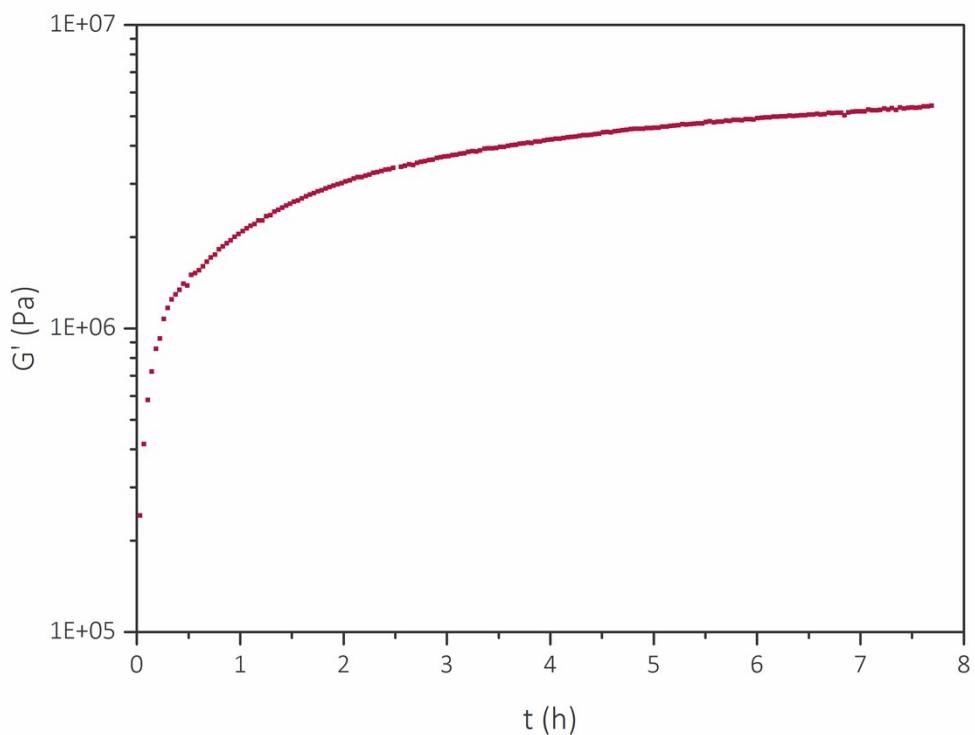


Figure S11. Curing step at 150 °C monitored by the evolution of the material storage modulus G'

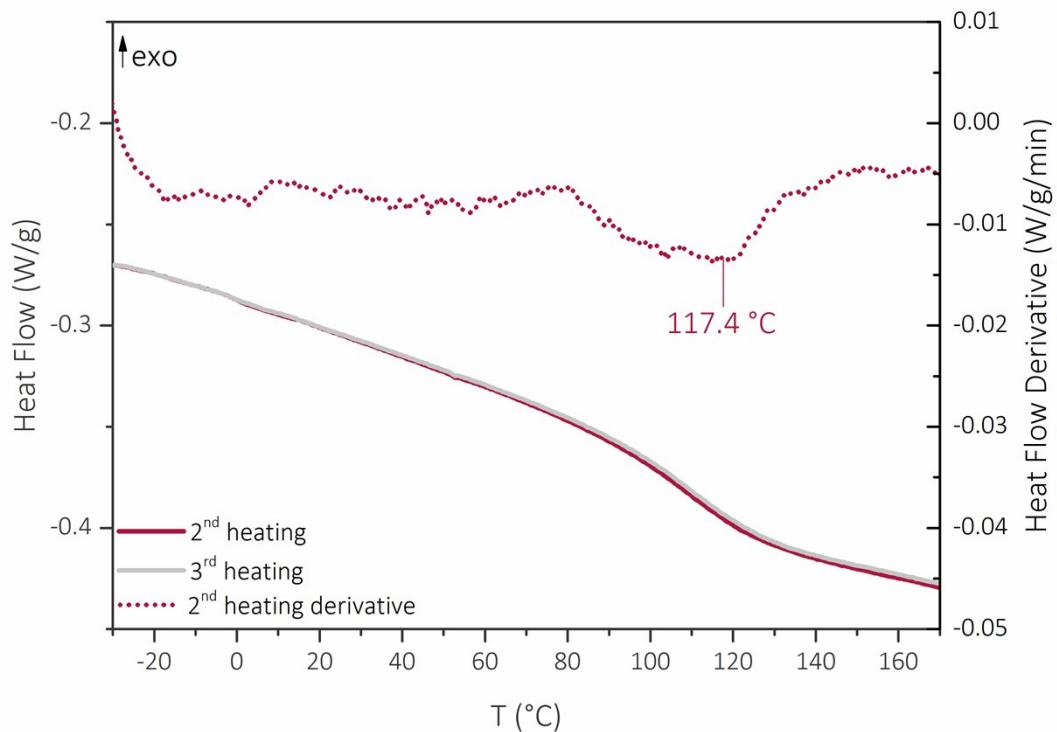


Figure S12. DSC thermogram of Vm-RvOH after complete curing 10 h at 150 °C.

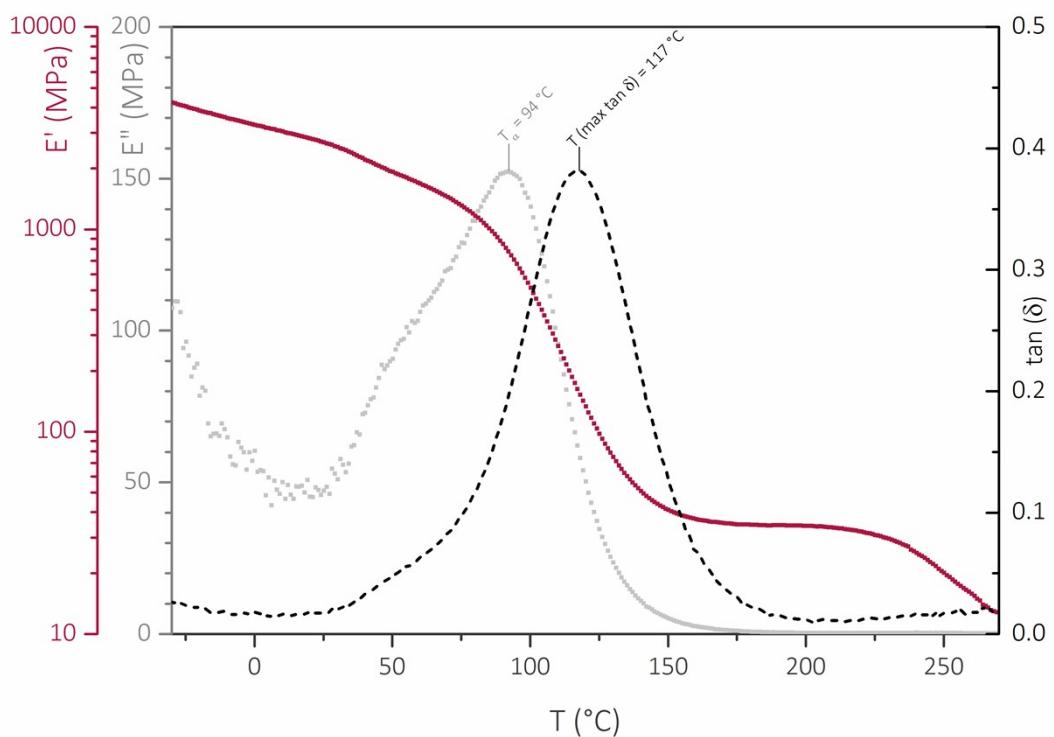


Figure S13. DMA thermogram of Vm-RvOH after complete curing 10 h at 150 °C (0.1 % strain, 1 Hz, 3 °C/min)

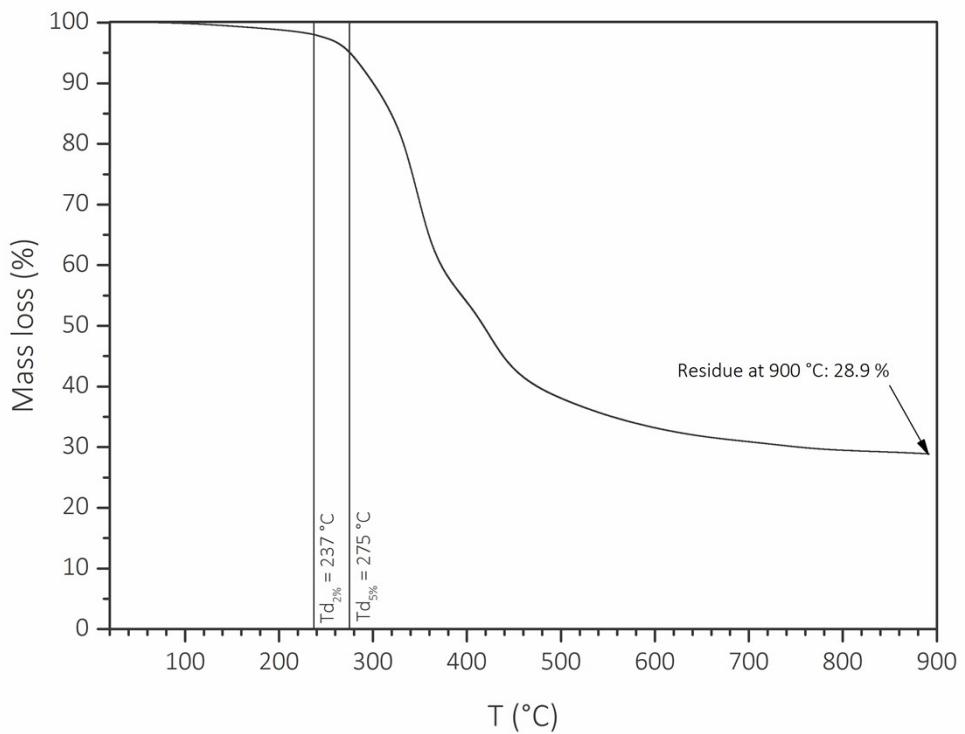


Figure S14. TGA thermogram under nitrogen of Vm-RvOH after complete curing 10 h at 150 °C

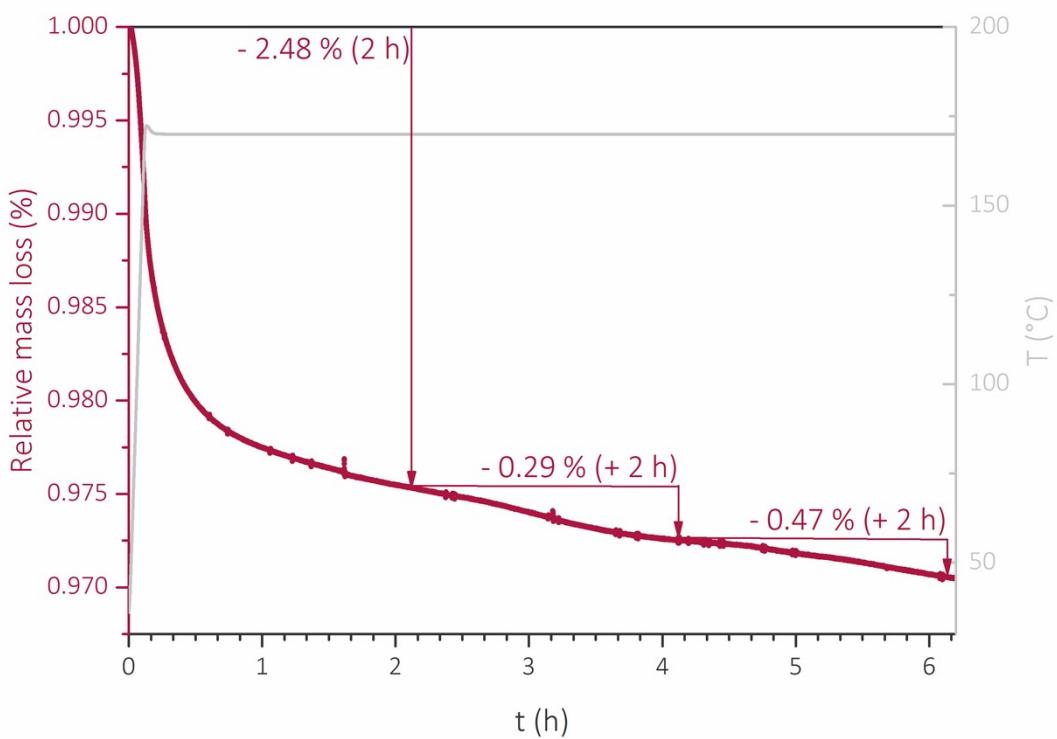


Figure S15. Isothermal TGA thermogram at 170 °C under air of Vm-RvOH after complete curing 10 h at 150 °C

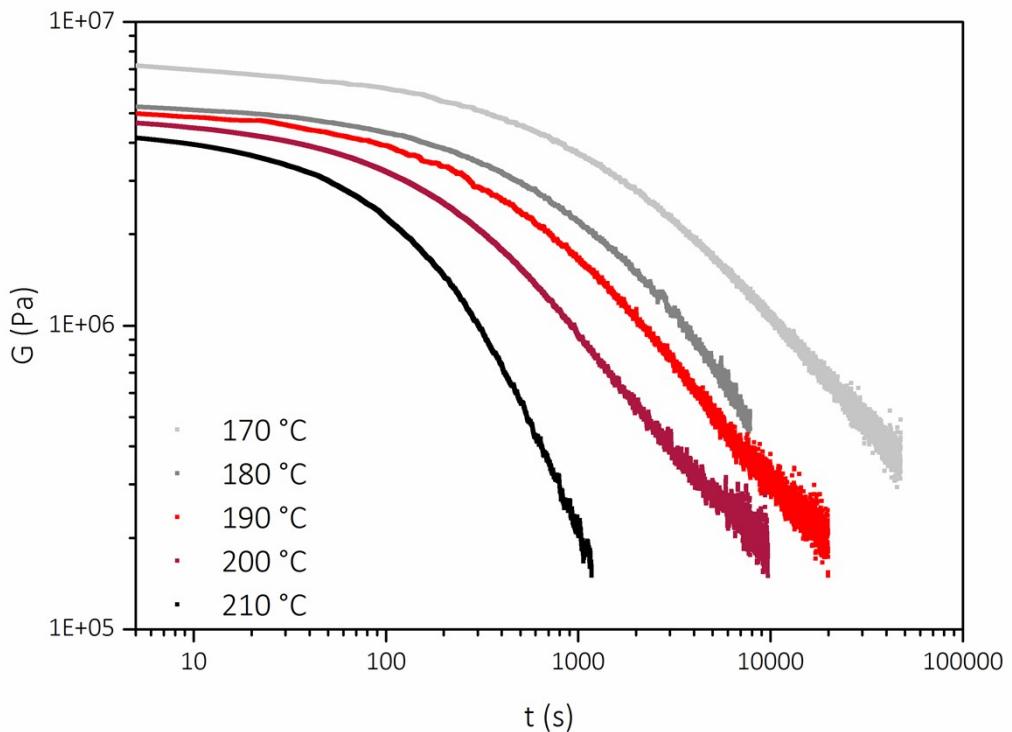


Figure S16. Stress-relaxation curves of Vm-RvOH from 170 to 210 °C with 10 °C steps (0.3 % strain)

Table S1. Equation and fitting parameters of the Kohlrausch-Williams-Watts stretched exponential for the stress relaxation experiments

$\frac{G}{G_0} = e^{\left(\frac{-t}{\tau}\right)^\beta} + y_0$	T (°C)	170	180	190	200	210
	τ (s)	1827	1042	648	333	156
	β	0.486	0.569	0.593	0.642	0.797
	y₀	0.043	0.049	0.060	0.064	0.053
	R²	0.99962	0.99975	0.99937	0.99974	0.99979

Note: for β = 1 and y₀ = 0, the KWW expression becomes a Maxwell

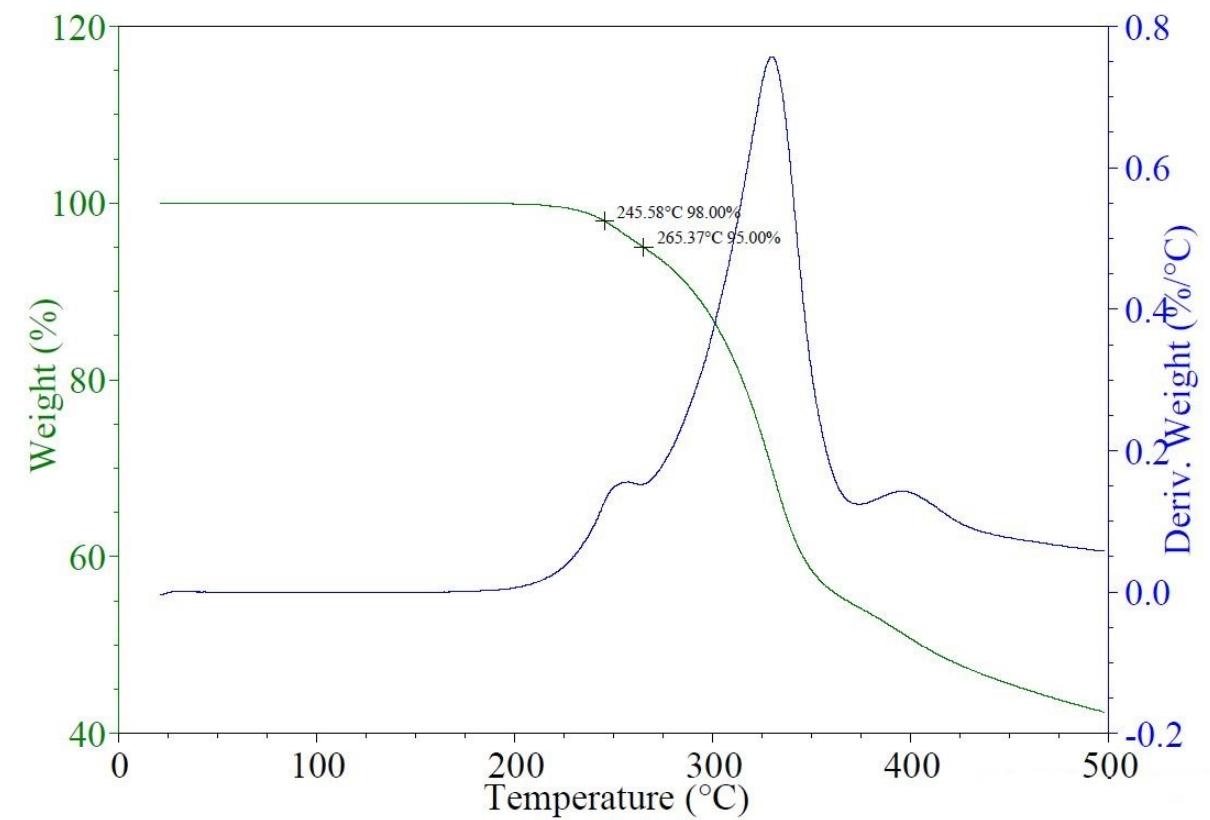


Figure S17. TGA thermogram under nitrogen of Vm-RvOH after complete curing 10 h at 150 °C recorded at 5 °C/min